FORM PTO- To: U.S. Der (PW FORM I	oartm	ent of Commerce	•					Atty. Dkt. No.	M#	14		C	lient	Ref.			
		ademark Office					•		•	•							
						•	·		306	 526			2-150	98.0	10-US		
INFORMA	AOIT	I DISCLOSUF	RE ST	ATEN	IENT			Applicant	•	Intonius T. A	A. M. I						
BY APPLI			•					L									
								Appln. No	).: L	Inknown							
		_			_	November 1	2, 200	03									
Date: No	veml	per 12, 2003	Page	1	of	3	<u> </u>	Examiner	: Unk	nown	Gro	up A	rt Ur	nit: L	Jnknow	<u>n</u>	
U.S. PATEN	NT DO	OCUMENTS		,													
Examiner's		Document				Name					Clas		Sub		Filing		
Initials*		Number	MM/	YYY	(Family N	Name	of First Inv	entor)	)		C	Class	3	Date			
	AR	3,573,975	04/19	71	Dhaka <i>et</i>	2/			<del></del>	117	212			(if appropriate			
	BR	3,648,587	03/19		Stevens	aı.				95		4		<del> </del>			
***************************************	CR	4,346,164	08/19		Tabarelli	et al				430	-	11		<del>                                     </del>			
	DR	4,396,705	08/19		Akeyama					430	-	326		<del>                                     </del>			
	ER	4,480,910		<del>                                     </del>		Takanash					355	<del></del>	30		<del>                                     </del>		
	FR	4,509,852				Tabarelli	et al.	· · · · · · · · · · · · · · · · · · ·			355	<del></del>	30				
	<del>                                     </del>	5,040,020		08/1991		Rauscher	nbach	et al.		355	5	53		<del>                                     </del>			
	HR	5,121,256		06/1992		Corle et a	ıl.				359		664		1		
	IR	5,610,683		03/19	97	Takahash	ni				355	5	53				
	JR	5,715,039	039		98	Fukuda e	Fukuda <i>et al.</i>				355	5 5		53			
	KR	5,825,043		10/19	10/1998 S						250	5	48				
	LR	5,900,354		05/19	99	Batchelde	er				430	395					
	MR	6,191,429		02/20	01	Suwa					250	5	48				
NR 6,560,032				05/20	03	Hatano			359	656							
FOREIGN F	PATE	NT DOCUMEN	TS		_							Engli			Translat		
		Document Date Number MM/Y		Count		try Inve		ntor Name			Abstra				Readily Available	Available	
											·						
							-				<del></del>	Enclo	osed	No	Enclose	No	
		WO 99/49504	09/199		PCT	· · · · · · · · · · · · · · · · · · ·	+	mi et al.				×			Х	lacksquare	
	<del>                                     </del>	EP 0023231	02/198		Europ		+	relli et al.				Χ.				+	
	QR	EP 4000544	03/199			<u>_</u>					X				X	╀	
	RR	EP 1039511	09/200				1	kimi et al.				X			X	+	
	SR TR	DD 224448 DD 242880	07/1985 02/1987		German German		+	Hesse et al. Kuch		•		<u> </u>		X X	<del> </del>	╁	
	UR	FR 2474708	07/1981		France		+	etellier				<del> </del>		^_ X	<b> </b>	+	
	VR	JP 62-065326		03/1987				ıchi			×		_		+		
	WR	JP 62-121417	06/198				Naka					X				+	
	XR	JP 63-157419	+	06/1988 Japan			Naka					x				T	
OTHER (Inc	<del></del>	g in this order A	<del> </del>		<del></del>		<del></del>		t Page	es etc.)						十	
<u> </u>	YR	EP Search Repo							ii i ag	00, 0.0./		1				•	
. =	ZR	M. Switkes et al. December 17, 2	, "lmme						Lab,	Orlando 2001	-1,					T	
	AAR	M. Switkes et al., "Immersion Lithography at 157 nm", J. Vac. Sci. Technol. B., Vol. 19, No. 6, November/December 2001, pp. 2353-2356															
	BBR	M. Switkes et al. September 4, 20	, "lmme				s for t	he 50 nm N	ode", 1	I57 Anvers-1	•					Γ	
Examiner				-	,			Date Con	sidere	:d:							
*EXAMINER		nitial if citation co						conforman	ce with	MPEP § 609	). Dra	w line	thro	ugh	citation	if	

(PW FORM	partme PAT-14	nt of Commerce				( <b>9</b> 4		Atty. Dkt. No.	M#	·		C	lient	Ref.		
									200	2704					40.110	
INFORMA BY APPLI		DISCLOSURE	STA	TEME	ТИ			Applicant:	-	3781 Joeri LOF <i>e</i>	t al.		<u>03</u>	31.0	10-US	
								Appln. No	.: <b>l</b>	Jnknown						
ļ								Filing Date	e: No	ovember 12	, 2003	3				
Date: Nov	ember	12, 2003	Page	2	of	3	<u></u>	Examiner					rt Ur	nit: L	Jnknow	n
U.S. PATE	NT DO	CUMENTS														
Examiner's				Date		Name			Class		Sub		Filing			
Initials*		Number	MM/YYYY		YYY	(Family Nam		e of First Inventor)				C	Class		Date (if appropriate	
	CCR	6,603,130		08/2003		Bisscho	ns et a				250	-	492.1		(if approp	onate
	<del>1</del>	6,633,365		10/2003		Suenaga		***			355		53		1	
	<del>)                                    </del>	2002/0163629		11/2002		Switkes		<del></del>		355		53				
	FFR	2003/0123040		07/2003		Almogy				355	6	69				
	GGR	2003/0174408		09/2003		Rostalsk	ci <i>et al</i>	•		359	6	642				
	HHR															
	IIR			ļ		_					ļ				-	
	JJR			-											<del> </del>	
	KKR			<del></del>				·							<u> </u>	
	LLR											$\dashv$			<del>                                     </del>	
	MMR										-	+			<del> </del>	
	NNR										_	$\dashv$			<del> </del>	
	OOR PPR						,				+	-+			<del> </del>	
FORFIGNI	<del></del>	IT DOOL IS AFSIT				1						Englis			Translat	<del></del>
FOREIGINI	ATEN	T DOCUMENTS Document Number	Date MM/Y		Cou	ntry	Inve	ntor Name				Abstr			Readily Availabl	
		, tambol										Enclo	sed	No	Enclose	No
	QQR	JP 04-305915	10/19	92	Japa	n	Ozek	ti <i>et al</i> .				Х				
	RRR	JP 04-305917	10/19	92	Japa	n	Ozek	i <i>et al</i> .				X				
	SSR	JP 06-124873	05/1994		Japan		Taka	akahashi		ļ	X				×	
	TTR	JP 07-220990		08/1995		Japan		ukuda et al.			X			<u> </u>	<u> </u>	$\perp$
		JP 10-228661	08/19			Japan		ırokawa			X			<u> </u>	<del> </del>	_
<u> </u>		JP 10-255319	09/19		Japan		+	uenaga et al.			X			<u> </u>	<del> </del>	$\bot$
	<del></del>	JP 10-303114	11/19		Japan		Suwa				X			<u> </u>	X .	+
		JP 10-340846 JP 2001-091849		12/1998		Japan			-		X		<u> </u>	X	+	
	YYR	JP 2001-091849	04/20	JT	Japa	n	Aizar	d <i>et al</i> .				*				
	ZZR						<u> </u>									
OTHER (In	cluding	in this order Au	thor, T	itle, Pe	riodic	al Name	e, Dat	e, Pertinen	t Pag	es, etc.)						
	AAAR	B.J. Lin, "Drivers, September 2002	Prosp	ects and	d Cha	llenges fo	r Imm	ersion Litho	graph	y", TSMC, Ir	ıc.,					
	BBBR	B.J. Lin, "Proximit No. 11B, April 19			ough l	iquid", IB	M Ted	chnical Discl	osure	Bulletin, Vo	1.20,					
Examiner			· · · · · ·					Date Cons	sidere	ed:					<del>1</del>	
*EXAMINEI	R: In	itial if citation cons	sidered	, wheth	er or r	not citatio	n is in				9. Dra	w line	thrc	uah	citation	if
not in confor		and not considere														

FORM PTO-1449 (modified) To: U.S. Department of Commerce								Atty. Dkt. No.	M#						
(PW FORM			•					DKT. NO.		•					
		ademark Office							• t						
							•		306781			D 00	04.0	40.110	
INFORMA	AOIT	I DISCLOSUF	PE ST	ATER	AENT	Applicant	•	F et a		IP-03	81.0	10-US			
BY APPLI			(L J)	A1 L10	71 <b>–</b> 171			фрисан	. 0001120	. 0					
								Appln. No	o.: Unknow	n					
					_	Filing Dat	e: Novembe	2003							
Date: Nove	embe	r 12, 2003	Page	<u></u> 3	of	3	<u> </u>	Examine	: Unknown		Grou	p Art U	nit: L	Jnknowr	n
	NT DO	OCUMENTS		,		1									
Examiner's		Document Number			Date Name						Class			Filing	
Initials*					MM/YYYY (Family Nam		vame	of First Inv		Class		Date (if appropriate			
	ccc														
	DDD														
	EEE			<u> </u>				<del>"</del>						<u> </u>	
FOREIGN F	PATE	NT DOCUMEN	1		<del></del>		_		1	_		English Abstract		Translati Readily	ion
	Document Date		Country		Inve	ntor Name			ľ	1000001			ilable		
:		Number		111								Enclosed	No	Enclose	TNI
	FFFF				<del>-  </del>	_ · ·		<del>!</del>				Inclosed	140	Enclose	130
	GGG				<del> </del>								<u> </u>	<u> </u>	十
OTHER (Inc		g in this order A	Author,	Title,	Period	lical Name	e, Dat	e, Pertiner	t Pages, etc.	)			<u> </u>		T
		B.J. Lin, "The Pa	ths To	Subha	If-Micro	ometer Opt	ical Li								
		Optical/Laser Mi						Mark Dafa	-4-" O-U-I O4-4	_					
	IIIR	G.W.W. Stevens Technology, Aug	ust 19	78, Vol	i.21 00	te Resultin 8, pp. 68-7:	g from 2	Mask Dete	cts", Solia Stat	e					
	JJJR	S. Owa et al., "Immersion Lithography; its potential performance and issues", SPIE													T
	KKK	Microlithography 2003, 5040-186, February 27, 2003  S. Owa et al., "Advantage and Feasibility of Immersion Lithography", Proc. SPIE 5040													
· 	<u> </u>	(2003)													
	LLLF	Nikon Precision Europe GmbH, "Investor Relations – Nikon's Real Solutions", May 15, 2003													
	ММК	H. Kawata et al. Greater than Uni													
	NNN	J.A. Hoffnagle et Vac. Sci. Techno	t al., "Li	quid In	nmersi	on Deep-U	Itraviol	et Interfero	metric Lithogra		J.	-			
	000	B.W. Smith <i>et al</i> Vol. 15, July 11,		ersion	Optica	l Lithograpl	hy at 1	93nm", FU	TURE FAB Inte	rnatio	nal,	-			Ī
	PPPI	H. Kawata et al., with an Oil Imme	"Fabric							thogra	phy				
	QQC	G. Owen et al., " November/Dece	1/8µm	Optical	Lithog	raphy", J. \				o. 6,					T
	RRR							<u>.</u>							一
	SSSI														
	TTTF	<del></del>													$oxed{oxed}$
	UUU	,							<del>-</del>		-				<u> </u>
<del></del>	VVVI WW										<u> </u>				├
	XXXI	-				·			* ·						$\vdash$
<del></del>	YYYI														$\vdash$
		<u> </u>	<del></del>					<del></del>						i	<u> </u>